Specimen preparation devices, specimen holders, and imaging detectors for electron microscopy



lon beam preparation



MODEL 1080 PicoMill[®] TEM specimen preparation system

Combines an ultra-low energy, inert gas ion source, and a scanning electron column with multiple detectors to yield optimal TEM specimens.

- Achieve ultimate specimen quality free from amorphous and implanted layers
- Complements FIB technology
- Milling without introduction of artifacts
- Advanced detector technology for imaging and precise endpoint detection
- In situ imaging with ions and electrons
- Microscope connectivity for risk-free specimen handling
- Adds capability and capacity
- Fast, reliable, and easy to use

MODEL 1040 NanoMill® TEM Specimen Preparation System

Uses an ultra-low energy, concentrated ion beam to produce the highest quality specimens for transmission electron microscopy (TEM)

- Variable energy ion source generates ion energies as low as 50 eV and a beam size as small as 1 μm
- Ultra-low-energy, inert-gas ion source
- Removes damaged layers without redeposition
- Ideal for post-focused ion beam processing
- Enhances the results from conventionally prepared specimens
- Room temperature to cryogenically cooled NanoMillings process
- Rapid specimen exchange for high-throughput applications
- Computer-controlled, fully programmable, and easy to use
- Contamination-free, dry vacuum system



MODEL 1060 SEM Mill

A state of the art ion milling and polishing system. It is compact, precise, and consistently produces high-quality SEM samples for a wide variety of applications.

- Two independently adjustable TrueFocus ion sources
- High energy operation for rapid milling; low energy operation for sample polishing
- Adjustable beam diameters
- Continuously adjustable milling angle range of 0 to +10°
- Sample rocking or rotation
- Basic and premium editions (basic edition shown at right)



MODEL 1050 TEM Mill

A state of the art ion milling and polishing system that consistently produces high-quality TEM specimens with large electron transparent areas.

- Two independently adjustable TrueFocus ion sources
- High energy operation for rapid milling; low energy operation for specimen polishing
- Ion source maintains a small beam diameter (100 eV to 6 keV operating energies)
- Continuously adjustable milling angle range of -10 to +10°
- Liquid nitrogen-cooled specimen stage
- Basic and premium editions (premium edition shown at left)



MODEL 1063 WaferMill[™] ion beam delayering solution

Full-wafer specimen preparation. With the WaferMill solution for CD-SEM specimen preparation, you can delayer multiple pre-selected regions on a full wafer. The entire process is automated; there is no need to manually touch a wafer.

- Selected-area milling on full 300 mm wafers
- Top-down delayering
- Expose multiple device layers and structures
- For use in multiple areas of a semiconductor fabrication facility:
- Research and development
- Process control
- Yield enhancement
- Failure analysis





Contamination solutions



MODEL 190 Cryo-Can

Eliminates sample contamination during SEM operation.

- Simple, economical, and reliable technique to remove organic contamination from the SEM
- The SEM can be used while the Cryo-Can is cooled, even on SEMs without airlocks
- Contaminants condense onto a removable, cold surface that can be regenerated and reused
- No separate vacuum or electrical interface required
- Noticeably improves resolution by reducing water vapor and hydrocarbons
- No internal cryo blade that restricts sample movement

MODEL 1020 Plasma Cleaner

Cleans specimens immediately before they are inserted into the electron microscope; removes existing carbonaceous debris from the specimen and prevents contamination from occurring during imaging and analysis.

- Simultaneously cleans specimen and specimen holder
- Cleans highly contaminated specimens in 2 minutes or less
- No change to the specimen's elemental composition or structural characteristics
- Oil-free vacuum system
- Readily accepts side-entry specimen holders for all commercial TEM and scanning transmission electron
 microscopes (STEM)
- · For SEM, as well as other surface science techniques
- · Handy for evacuating specimen holder vacuum storage containers



Model 9020 Vacuum Pumping Station

The Vacuum Pumping Station allows for the simultaneous vacuum storage of up to five plasmacleaned specimens TEM specimen holders.

- Includes a heavy-duty metal base
- Five Model 9010 Vacuum Storage Containers
- A vacuum pumping manifold
- All of the necessary components for connection to the Model 1020 Plasma Cleaner.

Imaging



Captures images formed by collecting electrons that have been forward scattered through high angles using high angle annular dark field STEM.

Removes existing carbonaceous debris from the specimen and holders; prevents contamination

Multifunctional; simultaneously cleans specimens, specimen holders, and stubs

Compatible with side-entry holders for all commercial SEM, TEM, and STEM

Inductively coupled, downstream plasma for optimal performance Sputter-free; no change to elemental composition or structural characteristics

Accepts two electron microscopy specimen holders

Multiple gas inlets with mixing capabilities Handy for evacuating vacuum storage containers

- Simultaneous high-angle annular dark field imaging and electron energy loss spectroscopy
- Yields Z-contrast information

MODEL 1070 NanoClean

during imaging and analysis.

Accommodates large objects

- Single electron detection
- Fully retractable from beam path









Conventional specimen preparation



MODEL 110 Automatic Twin-Jet Electropolisher

Used for the electrolytic thinning of TEM specimens. The twin-jet technique simultaneously polishes both sides of the specimen, creating electron transparency within a few minutes.



MODEL 130 Specimen Punch Produces high-quality disk specimens from thin metal foils. A precision ground punch and die plate eliminate specimen stress and distortion.



MODEL 160 Specimen Grinder Mechanically prethins specimens for TEM. Greatly reduces the time spent during the final preparation process of ion beam milling.



MODEL 170 Ultrasonic Disk Cutter Creates disk, cylindrical, and rectangular specimens; disk specimens from materials as thin as 10 µm, rods up to 10 mm long, and rectangular wafers for TEM cross-section (XTEM) specimens.



MODEL 180 XTEM Prep Kit Includes all the components required to produce high-quality cross-section specimens for TEM. Stacks and holds cross-section specimens, aligns areas and interface of interest, and produces consistent glue layer thickness.



MODEL 200 Dimpling Grinder An easy to use, state of the art, mechanical thinning instrument designed for the reproducible preparation of high-quality electron microscopy specimens.

Holders



MODEL 2020

Advanced Tomography Holder A revolutionary holder that allows room temperature data collection over wide tilt and translation ranges, even in restrictive polepiece gap geometries.



MODEL 2021 Analytical Tomography Holder

Optimizes the acquisition of elemental composition and structural information in three dimensions. Beryllium tip and clamps reduce the addition of spurious or system radiation.



MODEL 2030 Ultra-Narrow Gap Tomography Holder Capable of tilting up to 90° while providing a maximized field of view for TEM.



MODEL 2040 Dual-Axis Tomography Holder Features an optimal tilt angle range in narrow gap (~ 5 mm) pole-piece geometries while maintaining microscope resolution.



MODEL 2045 Motorized Dual-Axis Tomography Holder A holder that features an optimal tilt angle range in narrow gap (~ 5 mm) pole-piece geometries, while maintaining microscope resolution. Motorized rotational control for high throughput applications.



MODEL 2050 On-Axis Rotation Tomography Holder Accepts either rod- or cone-shaped specimens and rotates them fully through 360° about the axis of the holder.



Model 2550 Cryo Transfer Tomography Holder This single-tilt, liquid nitrogencooled, cryo transfer TEM specimen holder achieves a base temperature of better than -170 °C. Designed for cryo transfer and tomography of thin-film frozen-hydrated/vitrified specimens for low-dose imaging and analysis. The optional Model 9030 Turbo Pumping Station evacuates the dewar during zeolite regeneration.



Model 2560 Vacuum Transfer Tomography Holder

The holder is ideal for sensitive specimens that can be altered by environmental conditions; the specimen can be transferred in the presence of vacuum or an inert gas environment.



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